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In re application of

HALL, Stephen Ivor et al

Serial No. 10/694,827

Filed: 10/29/2003

For: TREATMENT OF GASEOUS EMISSIONS

LIST OF DOCUMENTS SUBMITTED BY APPLICANT
WITH INFORMATION DISCLOSURE STATEMENT
(Substitute Form PTO-1449)

U.S. Patent Documents (Number, Issue Date, and Patentee)					
Examiner Initial	Document Number	Document Date	Patentee	Class/ Subclass	
<i>JMA</i>	3,983,021	09/28/1976	HENIS	204	164
<i>JMA</i>	4,276,066	06/30/1981	BLY	55	287
<i>JMA</i>	4,427,418	01/24/1984	KOGISO	55	287
<i>JMA</i>	4,485,622	12/04/1984	TAKAGI	60	298
<i>JMA</i>	4,505,107	03/19/1985	YAMAGUCHI	60	303
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<i>JMA</i>	5,147,516	09/15/1992	MATHUR	204	177
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<i>JMA</i>	5,284,556	02/08/1994	RICH	204	164
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<i>JMA</i>	5,711,147	01/27/1998	VOGTLIN	60	274
<i>JMA</i>	5,715,677	02/10/1998	WALLMAN	60	274

Foreign Patent Documents (Number, Publication Date, and Country or Patent Office)					
Examiner Initial	Document Number	Document Date	Country	Translation yes no	
<i>JMA</i>	0 010 384	04/30/1980	EPO		
<i>JMA</i>	0 112 634	07/04/1984	EPO		
<i>JMA</i>	0 132 166	01/23/1985	FR		X
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<i>gnt</i>	6-106025	04/19/1994	JP		X
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<i>gnt</i>	98/09699	03/12/1998	WIPO		

Other Documents (Including Author, Title, Date and Place of Publication, Pertinent Pages, Etc.)	
<i>gnt</i>	M. Sholef, "Selective Catalytic Reduction of NO _x with N-Free Reductants," CHEM. REV., 1995, Volume 95, pages 209-225.

James N. Stewart
Examiner:

4/15/05
Date Considered

Examiner: Initial if reference considered. Draw line through citation if not in conformance and not considered.
Include copy of this form with next communication to applicant.